# III-V lab

## Indium Phosphide Photonic Integrated Circuit Open Foundry Offer (SIBH-OPIC-1.0)



The III-V Lab O-band SIBH-OPIC-1.0 InP Photonic Integrated Circuit technology is now available as a flexible Multi-Project-Wafers offer.

SIBH-OPIC-1.0 is a High-Performance
 O-Band Technology suitable for
 demanding Photonics Applications in
 terms of:

- Thermal Efficiency
- Optical Power
- Active and Passive Building Blocks Integration
- Strong competitive advantage thanks to Semi Insulating Buried Heterostructure (SIBH) associated to Aluminium Quantum Wells:
  - High energy efficiency for lasers and gain sections
  - Fully compatible with very high-speed modulators
  - Compatible with spot size converters

**Parameters** 

Good thermal dissipation

RR

Suitable for high temperature operation

GaInAsP		GaInAlAs
СВ	$\Delta E_{\rm c}$	
VB	<u>*</u>	
Alumini	um Quant	um Wells
	(5)	
(3)	(4) (2) (3) (1) (5) (4) (3) (4) (3) (4) (4) (3) (4) (4) (4) (4) (4) (4) (4) (4	(1) n-doped InP (2) active region (3) semi-insulating InP (4) p-doped InP (5) metal contacts
	SIBH	
ВВ	Parameters	Performance Indicators
Straight WG	Length	• Loss: <3dB/cm
Curved WG	Bending radius	<ul> <li>Excess Loss &lt; 0.5dB for bending radius &gt;</li> </ul>

		Indicators
DFB	Length	<ul> <li>Threshold Current @ 45°C: &lt;10mA</li> </ul>
DFB	Phase shift	<ul> <li>Slope Efficiency @ 45°C: 0.15W/A</li> <li>Emission Wavelength Range: 1260nm-1320nm</li> <li>SMSR: &gt;45dB</li> </ul>
	Emission wavelength	
EAM	Length	• SER @-2V: 9dB
LAIVI		• E/O BW: >30GHz
SOA	Length	<ul> <li>Gain: 47.8cm-1 @ 4.17kA/cm2 Current Density and -25dBm Pin</li> </ul>

BB	Parameters	Performance Indicators	
ht WG	Length	• Loss: <3dB/cm	
d wg	Bending radius	<ul> <li>Excess Loss &lt; 0.5dB for bending radius &gt; 500um</li> </ul>	
IMI*	Length: 301µm	• Excess loss: <1dB	
ММІ	Width: 15µm	Excess loss: <10B	
	Length: 915µm	5 1 4 10	
ММІ	Width: 23µm	Excess loss: <1dB	
	Length	<ul> <li>Reflectivity up to 95%</li> <li>Thermal tuning range: &lt;= 5nm</li> </ul>	
	Wavelength		
	Sampling		
SSC	Maximum output mode diameter	<ul> <li>Mode diameter : H: 3μm x V: 3μm</li> </ul>	

(\*) 2x1MMI and 2x2MMI have only fixed geometries. All other building blocks offer a larger range of geometries. Please refer to the Design Manual for more details.

2x1 M

2x2 M

DBR

SSC

DFB : Distributed Feedback Laser EAM : Electro Absorption Modulator

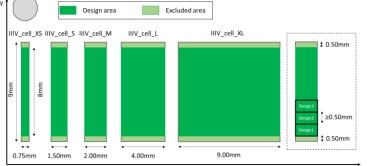
Performance

SOA : Semiconductor Optical Amplifier WG : Waveguide

You can easily design your own high performance functions by using a comprehensive Process Design Kit compatible with the main photonic design and simulation tools available on the market. The main available building blocks are illustrated above. More are available in our Design Manual available on demand at foundry@3-5lab.fr.

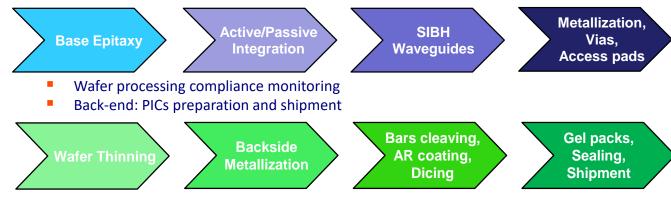


- The design cell area can be selected to perfectly match with your project from 0.75x8.00 mm<sup>2</sup> to 9.00x8.00 mm<sup>2</sup>.
- Several cells can be ordered depending on the required amount of different PIC designs.



#### A full turn-key MPW offer from Process Design Kit to diced PICs:

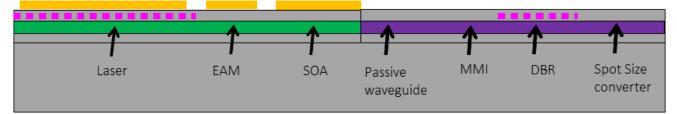
- 2 Multi-Project-Wafer runs per year / Dedicated runs on demand
- Process Design Kit and PIC design support
- Front-end: wafer manufacturing



At least one MPW run every 6 months taking advantage of the latest building blocks of the yearly PDK release. 1<sup>st</sup> MPW scheduled for second half 2024.

#### Future PDK releases will include:

- Selective area growth for active/active integration
- Semi-Insulating substrates for increased modulation speed
- Deep waveguides for better optical confinement and smaller waveguide bending radius
- Electro-optical phase modulators for increased modulation speed
- Photodiodes with telecom-grade bandwidth and responsivity



### **Cross-section view of a PIC**

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AT35/P/2024/04/0420 / April 12 2024 Early announcement, 1<sup>st</sup> MPW scheduled for second half 2024 III-V Lab is certified ISO9001-2015